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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/707,122	11/21/2003	Lawrence A. Clevenger	FIS920030220US1	1121
32074	7590 03/01/2005	•	EXAMINER	
INTERNATIONAL BUSINESS MACHINES CORPORATION			CHEN, JACK S J	
DEPT. 18G BLDG. 300-48	32		ART UNIT	PAPER NUMBER
2070 ROUTE 52 HOPEWELL JUNCTION, NY 12533			2813	
			DATE MAIL ED: 03/01/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Summary	10/707,122	CLEVENGER ET AL.				
Office Action Summary	Examiner	Art Unit				
	Jack Chen	2813				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the co	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be tim within the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from to cause the application to become ABANDONED	ely filed will be considered timely. the mailing date of this communication. (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on						
,-	- · · · ·					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	3 O.G. 213.				
Disposition of Claims						
4) Claim(s) 1-24 is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.						
6) Claim(s) is/are rejected.						
7) Claim(s) is/are objected to.						
8)⊠ Claim(s) <u>1-24</u> are subject to restriction and/or e	election requirement.					
Application Papers						
9) The specification is objected to by the Examine	۲.					
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correcti	on is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).				
11)☐ The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priori application from the International Bureau * See the attached detailed Office action for a list of	s have been received. s have been received in Application ity documents have been receive (PCT Rule 17.2(a)).	on No d in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te atent Application (PTO-152)				

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DETAILED ACTION

Election/Restrictions

1. Restriction to one of the following inventions is required under 35 U.S.C. 121:

 Claims 1-18 and 23-24, drawn to a method for forming an interconnect structure, classified in class 438, subclass 687.

II. Claims 19-22, drawn to interconnect structure, classified in class 257, subclass 300+.

The inventions are distinct, each from the other because of the following reasons:

- 2. Inventions I and II are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case, the product as claimed can be made by another and materially different process, such as instead of depositing a liner in the aperture and then removing the bottom portion of the liner to expose the lower interconnect member; one can selectively forming the liner through masking.
- 3. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.
- 4. Because these inventions are distinct for the reasons given above and the search required for Group I is not required for Group II, restriction for examination purposes as indicated is proper.

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Should Applicant elected the invention of Group I, then one of the following species must be elected:

5. This application contains claims directed to the following patentably distinct species of the claimed invention:

Species I (figs. 3-7) drawn to a method for forming an interconnect structure according to first embodiment. It appears that claims 1-11 and 23 read on this particular embodiment.

Species II (figs. 8-12) drawn to a method for forming an interconnect structure according to second embodiment. It appears that claims 12-18 and 24 read on this particular embodiment.

Should Applicant elected species I, then one from each of the following group must be elected:

A. material for the lower interconnect member (see specification, paragraph 0027)

A1. copper

A2. aluminum

A3. tungsten

B. material for the first liner (see specification, paragraph 0030)

B1. TaN

B2. Ta

B3. Ti

B4. Ti(Si)N

B5. W

C. material for the first liner (see specification, paragraph 0038)

C1. TaN

C2. Ta

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C3. Ti

C4. Ti(Si)N

C5. W

D. gas for ion bombardment (see specification, paragraph 0034)

D1. Ar

D2. He

D3. Ne

D4. Xe

D5. N2

D6. H2

D7. NH3

D8. N2H2

E. method for forming the first liner layer

E1. depositing a liner layer in the aperture then removing the liner layer on the bottom surface of the aperture (see specification, paragraph 0030-0034). It appears that claim 1 reads on this particular sub-species.

E2. simultaneously performing an ion bombardment and in-situ material deposition for the liner layer (see specification, paragraph 0035). It appears that claim 11 reads on this particular sub-species.

F. method for forming the second liner

F1. depositing the second liner layer on the lower interconnect. It appears that claim 2 reads on this particular sub-species.

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F2. depositing the second liner layer not on the lower interconnect. It appears that claim 23 reads on this particular sub-species.

Should Applicant elected species II, then one from each of the following group must be elected:

A. material for the lower interconnect member (see specification, paragraph 0027)

A1. copper

A2. aluminum

A3. tungsten

B. material for the first liner (see specification, paragraph 0030)

B1. TaN

B2. Ta

B3. Ti

B4. Ti(Si)N

B5. W

C. material for the first liner (see specification, paragraph 0038)

C1. TaN

C2. Ta

C3. Ti

C4. Ti(Si)N

C5. W

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D. gas for ion bombardment (see specification, paragraph 0034)

D1. Ar

D2. He

D3. Ne

D4. Xe

D5. N2

D6. H2

D7. NH3

D8. N2H2

E. method for forming the first liner layer

E1. depositing a liner layer in the aperture then removing the liner layer on the bottom surface of the aperture (see specification, paragraph 0030-0034, 0043).

E2. simultaneously performing an ion bombardment and in-situ material deposition for the liner layer (see specification, paragraph 0035 and 0044).

F. method for forming the second liner

F1. depositing the second liner layer on the lower interconnect. It appears that claim 13 reads on this particular sub-species.

F2. depositing the second liner layer not on the lower interconnect. It appears that claim 24 reads on this particular sub-species.

Applicant is required under 35 U.S.C. 121 to elect a single disclosed species for prosecution on the merits to which the claims shall be restricted if no generic claim is finally held to be allowable. Currently, no claim is generic.

Applicant is advised that a reply to this requirement must include an identification of the species that is elected consonant with this requirement, and a listing of all claims readable thereon, including any claims subsequently added. An argument that a claim is allowable or that all claims are generic is considered nonresponsive unless accompanied by an election.

Upon the allowance of a generic claim, applicant will be entitled to consideration of claims to additional species which are written in dependent form or otherwise include all the limitations of an allowed generic claim as provided by 37 CFR 1.141. If claims are added after the election, applicant must indicate which are readable upon the elected species. MPEP § 809.02(a).

Should applicant traverse on the ground that the species are not patentably distinct, applicant should submit evidence or identify such evidence now of record showing the species to be obvious variants or clearly admit on the record that this is the case. In either instance, if the examiner finds one of the inventions unpatentable over the prior art, the evidence or admission may be used in a rejection under 35 U.S.C. 103(a) of the other invention.

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

6. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jack Chen whose telephone number is (571)272-1689. The examiner can normally be reached on Monday-Friday (9:00am-6:30pm) alternate Monday off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead can be reached on (571)272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jack Chen

Primary Examiner Art Unit 2813

June 1

February 22, 2005